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(54) **Organic light emitting display**

Organische lichtemittierende Anzeige

Affichage électroluminescent organique

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(56) References cited:
JP-A- 2005 011 571 US-A1- 2005 116 232
US-A1- 2006 044 504

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Description

Field of the Invention

[0001] The present invention relates to an organic light emitting display, and more particularly, to an organic light emitting display in which signal lines disposed under a non-display region located out of a display region where an image is displayed, more specifically, a chip on glass (COG) region are prevented from being shorted.

Description of the Related Art

[0002] Recently, various flat displays capable of reducing weight and volume in comparison to cathode ray tube (CRT) displays have been developed.

[0003] Typically, a flat display device includes a liquid crystal display (LCD), a field emission display (FED), a plasma display panel (PDP), an organic light emitting display (OLED), and the like.

[0004] An organic light emitting display displays an image by driving N x M organic light emitting devices, which are emissive display elements for electrically exciting an organic compound to emit light, by using a voltage or current.

[0005] Since an organic light emitting device has diode characteristics, an organic light emitting device may also be referred to as an organic light emitting diode. An organic light emitting device includes an anode electrode that is a hole injection electrode, an organic thin film that is a light emitting layer, and a cathode electrode that is an electron injection electrode.

[0006] Accordingly, when holes and electrons are injected into the organic thin film, excitons obtained by combining the injected holes and electrons are transitioned from an excited state to a ground state and light is emitted from the organic light emitting device.

[0007] OLEDs including an organic light emitting device having the aforementioned structure can be classified into a passive matrix type OLED and an active matrix type OLED depending upon the driving type.

[0008] The structure of an active matrix type OLED will be described in detail.

[0009] An active matrix type OLED includes a first substrate provided with organic light emitting devices.

[0010] Here, the first substrate may be a driving circuit substrate including a driving circuit unit provided with TFTs.

[0011] The first substrate may be a display substrate not provided with the driving circuit unit, hereinafter, it is assumed that the first substrate is the driving circuit substrate.

[0012] The first substrate includes a display region, which is provided with organic light emitting devices, for displaying a predetermined image and a non-display region located outside the display region.

[0013] The display region is provided with a lower structure. A flattening layer is formed on the lower struc-

ture.

[0014] Here, the lower structure includes a plurality of thin film transistors and an interlayer insulation film for insulating the gate electrodes of the thin film transistors from the source and drain electrodes thereof.

[0015] In addition, an anode electrode electrically connected to the source and/or drain electrodes is formed on the flattening layer. The light emitting layer and a cathode electrode are sequentially formed on the anode electrode.

[0016] The organic light emitting device including the anode electrode, the light emitting layer, and the cathode electrode is separated from a neighboring sub-pixel by using a pixel defining layer.

[0017] The sub-pixel generally includes the light emitting layer for emitting red, green, or blue light.

[0018] Accordingly, a single pixel includes three sub-pixels for emitting light of each color of R, G and B. Full colors can be displayed by using a plurality of pixel.

[0019] The aforementioned organic light emitting display includes one or more driving ICs.

[0020] The driving ICs may be generally mounted by a tape automated bonding (TAB) or by a chip on glass (COG) method.

[0021] Here, the TAB method is a technique of mounting a tape carrier package (TCP) in which the driving IC is mounted, on the substrate, and the COG method is a technique of directly mounting the driving IC on the substrate.

[0022] In the COG method, a driving IC having a finer pitch can be mounted as compared with a pitch used for the TAB method. Accordingly, recently, the COG method has been widely used.

[0023] However, to apply the COG method, the COG region on which the driving IC is mounted has to be included on the substrate. In the past, a part of the non-display region disposed outside of the display region was used as the COG region.

[0024] Recently, a multi-panel process has been used to manufacture the organic light emitting display having the aforementioned structure.

[0025] Here, in the multi-panel process, a plurality of organic light emitting displays are formed on a mother glass, all the organic light emitting displays are enclosed by using encapsulation glass, and the encapsulation glass and the mother glass are cut in units of displays to provide a plurality of displays.

[0026] When the COG type organic light emitting display is manufactured in the multi-panel process, a part of the encapsulation glass is scribed and removed to expose the COG region, and the driving IC is mounted on the exposed COG region.

[0027] However, when the part of the encapsulation glass is removed, the flattening film is scratched by glass particles generated in the scribing process.

[0028] Accordingly, wirings under the COG region, which are formed on the same layer as the source and drain electrodes of the thin film transistor and protected

by the flattening film, are shorted in the process of fabrication. US2006/0044504 and JP2005-011571 disclose electro-optical devices.

SUMMARY OF THE INVENTION

[0029] The present invention sets out to provide an organic light emitting display capable of preventing wires disposed on a non-display region from being shorted.

[0030] According to a first aspect of the invention there is provided an organic light emitting display device as set out in claim 1. Preferred features are set out in claims 2 to 10. Different signals may be transmitted through the first and second signal lines, respectively.

[0031] In addition, the same signals may be transmitted through the first signal lines, and similarly, the same signals may be transmitted through the second signal lines.

[0032] According to a second aspect of the invention there is provided a method of fabricating an organic light emitting display device as set out in claim 11. Preferred features are set out in claim 12.

[0033] In the organic light emitting display having the aforementioned structure, the signal lines are prevented from being shorted. Accordingly, serious errors are prevented from occurring in driving the organic light emitting devices.

BRIEF DESCRIPTION OF THE DRAWINGS

[0034] The above and other features and advantages of the present invention will become more apparent by describing in detail exemplary embodiments thereof with reference to the attached drawings in which:

FIG. 1 is a top plan view illustrating a schematic structure of an organic light emitting display according to an embodiment of the present invention;

FIG. 2 is a cross-sectional view illustrating a schematic structure of a display region shown in FIG. 1; FIG. 3 is a cross-sectional view illustrating a schematic structure of a wiring section disposed under a non-display region shown in FIG. 1, more specifically, a COG region; and

FIG. 4 is a cross-sectional view illustrating a schematic structure of a wiring section according to an example not forming part of the present invention.

DETAILED DESCRIPTION OF THE EMBODIMENTS

[0035] The present invention will now be described more fully hereinafter with reference to the accompanying drawings, in which preferred embodiments of the invention are shown.

[0036] Like reference numerals designate like elements throughout the specification.

[0037] In the drawings, the thickness of layers, films, panels, regions, etc. are exaggerated for clarity. It will be

understood that when an element such as a layer, film, region or substrate is referred to as being "on" another element, it can be directly on the other element or intervening elements may also be present.

[0038] In contrast, when an element is referred to as being "directly on" another element, there are no intervening elements present.

[0039] As shown in FIG. 1, the organic light emitting display according to an embodiment of the present invention includes first and second substrates 10 and 20 facing each other.

[0040] Here, the first substrate 10 may be made of transparent glass, opaque resin, or metal foil.

[0041] The second substrate 20 enclosed in the first substrate 10 by using a sealant may be made of transparent glass or metal cap.

[0042] The aforementioned structure may be sealed by coating the structure of the first substrate 10 with a thin film.

[0043] The first substrate 10 includes a display region A1 and a non-display region A2. The display region A1 is provided with a plurality of organic light emitting devices 18 for displaying a predetermined image.

[0044] Hereinafter, referring to FIG. 2, a cross sectional structure of the display region A1 is described.

[0045] FIG. 2 is a cross-sectional view illustrating an active matrix type organic light emitting display serving as a bottom emission type device. A buffer film 12 is formed on the first substrate 10, and thin film transistors 14 constituting a driving circuit unit are formed on the buffer film 12.

[0046] More specifically, a semiconductor layer 14a is formed on the buffer layer 12, and a gate insulation film 14b is formed on the semiconductor layer 14a and the buffer layer 12.

[0047] Here, the semiconductor 14a is formed by patterning a polycrystalline silicon film into a predetermined shape and injecting impurities into the polycrystalline silicon film to form source and drain regions and a channel region interposed therebetween.

[0048] A gate electrode 14c is formed on the gate insulation film 14b, an interlayer insulation film 14d is formed on the gate electrode 14c and the gate insulation film 14b, and source and drain electrodes 14e and 14f are formed on the interlayer insulation film 14d.

[0049] The source and drain electrodes 14e and 14f are electrically connected to the source and drain regions of the semiconductor layer 14a, respectively, through a connection hole of the interlayer insulation film 14d.

[0050] A flattening layer 16 is formed on the thin film transistor 14 and the interlayer insulation film 14d, and an organic light emitting device 18 is formed on the flattening layer 16.

[0051] More specifically, an anode electrode 18a is formed on the flattening layer 16. The anode electrode 18a is electrically connected to the drain electrode 14f through a connection hole of the flattening layer 16. A light emitting layer 18b and a cathode electrode 18c are

sequentially formed on the anode electrode 18a.

[0052] The anode electrode 18a may be made of a transparent conductive material such as ITO or IZO to display light emitted from the light emitting layer 18b to the outside of the organic light emitting devices 18 through the anode electrode 18a and the first substrate 10.

[0053] The organic light emitting devices 18 including the anode and cathode electrodes 18a and 18c and the light emitting layer 18b are separated from neighboring elements by a pixel defining layer 18d.

[0054] The light emitting layer 18b may be constructed as a multilayer structure including a hole injection layer, a hole transport layer, and an electron transport layer to display one color of red, green, and blue.

[0055] Although not shown, an electron injection layer (EIL) may be further formed between the electron transport layer and the cathode electrode 18c.

[0056] The organic light emitting devices 18 having the aforementioned structure display a predetermined image by allowing the light emitted from the light emitting layer 18b to pass through the anode electrode 18a and the first substrate 10 and to be emitted to the outside of the organic light emitting devices 18.

[0057] A detailed structure of the aforementioned organic light emitting device and the thin film transistor may be changed according to a product specification.

[0058] The non-display region A2 disposed outside of the display region A1 includes a wiring section 30 for supplying a driving signal to the thin film transistor 14 or organic light emitting device 18.

[0059] As shown in FIG. 3, the wiring section 30 includes a plurality of signal lines 32 and 34. The driving signal is transmitted through the signal lines 32 and 34.

[0060] However, in prior devices, the signal lines 32 and 34, which are made of the same material as the source and drain electrodes 14e and 14f, have been formed on the interlayer insulation film 16.

[0061] Accordingly, when the non-display region that is not enclosed by the second substrate 20, is scratched in the process of fabrication, a short circuit occurs between the signal lines 32 and 34.

[0062] In the present embodiment, to prevent the short circuit between the signal lines 32 and 34, at the signal line 32 is formed on the gate insulation film 14b.

[0063] More specifically, the wiring section 30 according to an embodiment of the present invention includes a first signal line 32 formed on the gate insulation film 14b and a second signal line 34 formed on the interlayer insulation film 14d.

[0064] Although one first signal line 32 and one second signal line 34 are shown in FIG. 3, a plurality of first signal lines 32 and a plurality of second signal lines 34 are formed under the COG region A3 in the same pattern as FIG. 3, in practice.

[0065] The first signal line 32 may be made of the same material as the gate electrode 14c. The second signal line 34 may be made of the same material as the source

and drain electrodes 14e and 14f.

[0066] The wiring section 30 having the aforementioned structure is constructed so that different signals are transmitted through the first and second signal lines 32 and 34, respectively.

[0067] In this case, the same signals or different signals may be transmitted through the aforementioned first signal lines 32, and the same signals may be transmitted through the second signal lines 34.

[0068] The first and second signal lines 32 and 34 need not be alternately formed one by one.

[0069] For example, two or more first signal lines 32 protected by the interlayer insulation film 14d may be formed between the second signal lines 34.

[0070] On the other hand, in a reference example not forming part of the present invention, as shown in FIG. 4, all the signal lines constituting the wiring section 30, that is, the first and second signal lines 32 and 34 are made of the same material as the gate electrode 14c and formed on the gate insulation film 14b.

[0071] In the present example, two or more different voltages are transmitted through the signal lines 32 and 34.

Claims

1. An organic light emitting display device comprising:

- a first substrate (10) comprising a top surface;
- a second substrate (20);
- an array of organic light emitting pixels(18) interposed between the first substrate and the second substrate;
- a thin film transistor (14) interposed between the first substrate and the array of organic light emitting pixels, the thin film transistor comprising a semiconductor layer (14a), a gate electrode (14c), a source electrode (14e) and a drain electrode (14f), a gate insulation layer (14b) arranged between the semi-conductor layer and the gate electrode, and an interlayer insulation layer (14d) arranged between the gate electrode and the source and drain electrodes;
- a plurality of conductive lines (32 and 34) comprising first conductive lines and second conductive lines, wherein the first conductive lines are formed directly on the gate insulation layer and the second conductive lines are formed on the interlayer insulation layer; and
- a chip on glass (COG) region which does not overlap the array of organic light emitting pixels, wherein the first and second conductive lines are disposed in the COG region, **characterized in that** the gate insulation layer comprises a first extension, and wherein the first conductive lines are interposed between the first extension of the gate insulation layer and the interlayer insulation

- layer, wherein the interlayer insulation layer comprises a second extension, and wherein the second conductive lines are interposed between the second extension of the interlayer insulation layer and the array of organic light emitting pixels and the first and second conductive lines are substantially parallel to one another and not overlapping when viewed in a direction substantially perpendicular to the top surface.
2. A device according to Claim 1, wherein the first conductive lines (32) are made of the same material as the gate electrode.
 3. A device according to any preceding Claim, wherein the second conductive lines (34) are made of the same material as the source and drain electrodes (14e and 14f).
 4. A device according to any preceding Claim, wherein the first conductive lines (32) and the second conductive lines (34) are disposed in an alternating order along a direction substantially parallel to the top surface.
 5. A device according to any preceding Claim, wherein signals transmitted through the first conductive lines (32) are different from signals transmitted through the second conductive lines (34).
 6. A device according to any preceding Claim, wherein the array of organic light emitting pixels defines a display region confined by the first and second substrates (10 and 20) along a first direction substantially perpendicular to the top surface and by a perimeter surface along a second direction substantially parallel to the top surface, wherein the perimeter surface is extended between the first and second substrates and perpendicular to the top surface.
 7. A device according to Claim 6, wherein the array of organic light emitting pixels is provided in the display region, and wherein the thin film transistor (14) is provided in the display region.
 8. A device according to Claim 6 or 7, wherein the plurality of conductive lines are provided in a non-display region, wherein the non-display region comprises a region between the first and second substrates (10 and 20), and wherein the non-display region encloses the perimeter surface of the display region.
 9. The device of Claim 8, wherein the non-display region further comprises a chip on glass (COG) region, wherein the plurality of conductive lines are formed in the COG region.
 10. A device according to any preceding Claim, wherein

the first and second conductive lines (32 and 34) are for transmitting signals to the thin film transistor (14).

11. A method of fabricating an organic light emitting display device, the method comprising:

forming a semiconductor layer (14a) on a first substrate (10);
forming a gate insulation layer (14b) that comprises a first extension on the semiconductor layer;
forming a gate electrode (14c) and first conductive lines (32) directly on the gate insulation layer;
forming an interlayer insulation layer (14d) that comprises a second extension on the gate electrode and the first conductive lines wherein the first conductive lines are interposed between the first extension of the gate insulation layer and the interlayer insulation layer;
forming second conductive lines (34) on the interlayer insulation layer, wherein the first and second conductive lines are substantially parallel to one another and not overlapping when viewed in a direction substantially perpendicular to the top surface
forming source and drain electrodes (14e and 14f) on the interlayer insulation layer;
forming a flattening layer (16) on the source and drain electrodes;
forming an array of organic light emitting pixels on the flattening layer, wherein the second conductive lines are interposed between the second extension of the interlayer insulation layer and the array of organic light emitting pixels; and
forming a chip on glass (COG) region which does not overlap the array of organic light emitting pixels, wherein the first and second conductive lines are disposed in the COG region.

12. A method according to claim 11 further comprising forming the flattening layer (16) on the second conductive lines (34).

Patentansprüche

1. Organische lichtemittierende Anzeigevorrichtung, umfassend:

einen ersten Träger (10), umfassend eine obere Oberfläche;
einen zweiten Träger (20);
eine zwischen dem ersten Träger und dem zweiten Träger befindliche Anordnung organischer lichtemittierender Pixel (18);
einen zwischen dem ersten Träger und der Anordnung organischer lichtemittierender Pixel

- befindlichen Dünnschichttransistor (14), wobei der Dünnschichttransistor eine Halbleiterschicht (14a), eine Gate-Elektrode (14c), eine Source-Elektrode (14e) und eine Drain-Elektrode (14f), eine zwischen der Halbleiterschicht und der Gate-Elektrode angeordnete Gate-Isolierschicht (14b) und eine zwischen der Gate-Elektrode und der Source- und der Drain-Elektrode angeordnete Zwischenschicht-Isolierschicht (14d) umfasst; eine Mehrzahl leitfähiger Leitungen (32 und 34), umfassend erste leitfähige Leitungen und zweite leitfähige Leitungen, wobei die ersten leitfähigen Leitungen unmittelbar auf der Gate-Isolierschicht ausgebildet sind und die zweiten leitfähigen Leitungen auf der Zwischenschicht-Isolierschicht ausgebildet sind; und eine Chip-on-Glass-(COG-)Region, die keine Überlappung mit der Anordnung organischer lichtemittierender Pixel aufweist, wobei die ersten und zweiten leitfähigen Leitungen in der COG-Region angeordnet sind, **dadurch gekennzeichnet, dass** die Gate-Isolierschicht eine erste Verlängerung umfasst und wobei sich die ersten leitfähigen Leitungen zwischen der ersten Verlängerung der Gate-Isolierschicht und der Zwischenschicht-Isolierschicht befinden, wobei die Zwischenschicht-Isolierschicht eine zweite Verlängerung umfasst und wobei sich die zweiten leitfähigen Leitungen zwischen der zweiten Verlängerung der Zwischenschicht-Isolierschicht und der Anordnung organischer lichtemittierender Pixel befinden und die ersten und zweiten leitfähigen Leitungen bei Betrachtung in einer zu der oberen Oberfläche im Wesentlichen senkrechten Richtung im Wesentlichen parallel zueinander und nicht überlappend sind.
2. Vorrichtung nach Anspruch 1, wobei die ersten leitfähigen Leitungen (32) aus dem gleichen Werkstoff gefertigt sind wie die Gate-Elektrode.
 3. Vorrichtung nach einem der vorangehenden Ansprüche, wobei die zweiten leitfähigen Leitungen (34) aus dem gleichen Werkstoff gefertigt sind wie die Source- und die Drain-Elektrode (14e und 14f).
 4. Vorrichtung nach einem der vorangehenden Ansprüche, wobei die ersten leitfähigen Leitungen (32) und die zweiten leitfähigen Leitungen (34) in einer abwechselnden Reihenfolge entlang einer zu der oberen Oberfläche im Wesentlichen parallelen Richtung angeordnet sind.
 5. Vorrichtung nach einem der vorangehenden Ansprüche, wobei durch die ersten leitfähigen Leitungen (32) übertragene Signale sich von durch die zweiten leitfähigen Leitungen (34) übertragenen Signalen unterscheiden.
 6. Vorrichtung nach einem der vorangehenden Ansprüche, wobei die Anordnung organischer lichtemittierender Pixel eine Anzeigeregion definiert, die durch den ersten und den zweiten Träger (10 und 20) entlang einer zu der oberen Oberfläche im Wesentlichen senkrechten ersten Richtung und durch eine Begrenzungsfläche entlang einer zu der oberen Oberfläche im Wesentlichen parallelen zweiten Richtung begrenzt ist, wobei sich die Begrenzungsfläche zwischen dem ersten und dem zweiten Träger und senkrecht zu der oberen Oberfläche erstreckt.
 7. Vorrichtung nach Anspruch 6, wobei die Anordnung organischer lichtemittierender Pixel in der Anzeigeregion vorgesehen ist und wobei der Dünnschichttransistor (14) in der Anzeigeregion vorgesehen ist.
 8. Vorrichtung nach Anspruch 6 oder 7, wobei die Mehrzahl leitfähiger Leitungen in einer Nichtanzeigeregion vorgesehen ist, wobei die Nichtanzeigeregion eine Region zwischen dem ersten und dem zweiten Träger (10 und 20) umfasst, und wobei die Nichtanzeigeregion die Begrenzungsfläche der Anzeigeregion umschließt.
 9. Vorrichtung nach Anspruch 8, wobei die Nichtanzeigeregion weiterhin eine Chip-on-Glass-(COG-)Region umfasst, wobei die Mehrzahl leitfähiger Leitungen in der COG-Region ausgebildet ist.
 10. Vorrichtung nach einem der vorangehenden Ansprüche, wobei die ersten und zweiten leitfähigen Leitungen (32 und 34) zum Übertragen von Signalen an den Dünnschichttransistor (14) dienen.
 11. Verfahren zur Herstellung einer organischen lichtemittierenden Anzeigevorrichtung, wobei das Verfahren umfasst:
 - Ausbilden einer Halbleiterschicht (14a) auf einem ersten Träger (10);
 - Ausbilden einer Gate-Isolierschicht (14b), die eine erste Verlängerung umfasst, auf der Halbleiterschicht;
 - Ausbilden einer Gate-Elektrode (14c) und erster leitfähiger Leitungen (32) unmittelbar auf der Gate-Isolierschicht;
 - Ausbilden einer Zwischenschicht-Isolierschicht (14d), die eine zweite Verlängerung umfasst, auf der Gate-Elektrode und den ersten leitfähigen Leitungen, wobei sich die ersten leitfähigen Leitungen zwischen der ersten Verlängerung der Gate-Isolierschicht und der Zwischenschicht-Isolierschicht befinden;

Ausbilden zweiter leitfähiger Leitungen (34) auf der Zwischenschicht-Isolierschicht, wobei die ersten und zweiten leitfähigen Leitungen bei Betrachtung in einer zu der oberen Oberfläche im Wesentlichen senkrechten Richtung im Wesentlichen parallel zueinander und nicht überlappend sind;

Ausbilden von Source- und Drain-Elektrode (14e und 14f) auf der Zwischenschicht-Isolierschicht;

Ausbilden einer Glättungsschicht (16) auf der Source- und der Drain-Elektrode;

Ausbilden einer Anordnung organischer lichtemittierender Pixel auf der Glättungsschicht, wobei sich die zweiten leitfähigen Leitungen zwischen der zweiten Verlängerung der Zwischenschicht-Isolierschicht und der Anordnung organischer lichtemittierender Pixel befinden; und Ausbilden einer Chip-on-Glass-(COG-)Region, die keine Überlappung mit der Anordnung organischer lichtemittierender Pixel aufweist, wobei die ersten und zweiten leitfähigen Leitungen in der COG-Region angeordnet sind.

12. Verfahren nach Anspruch 11, weiterhin umfassend Ausbilden der Glättungsschicht (16) auf den zweiten leitfähigen Leitungen (34).

Revendications

1. Dispositif d'affichage électroluminescent organique comprenant :

un premier substrat (10) comprenant une surface supérieure ;

un deuxième substrat (20) ;

un réseau de pixels électroluminescents organiques (18) interposés entre le premier substrat et le deuxième substrat ;

un transistor à couche mince (14) interposé entre le premier substrat et le réseau de pixels électroluminescents organiques, le transistor à couche mince comprenant une couche semi-conductrice (14a), une électrode de grille (14c), une électrode de source (14e) et une électrode de drain (14f), une couche d'isolation de grille (14b) agencée entre la couche semi-conductrice et l'électrode de grille, et une couche d'isolation intermédiaire (14d) agencée entre l'électrode de grille et les électrodes de source et de drain ;

une pluralité de lignes conductrices (32 et 34) comprenant des premières lignes conductrices et des deuxièmes lignes conductrices, dans lequel les premières lignes conductrices sont formées directement sur la couche d'isolation de grille et les deuxièmes lignes conductrices sont formées sur la couche d'isolation intermédiaire ;

et

une région de puce sur verre (COG) qui ne se chevauche pas avec le réseau de pixels électroluminescents organiques, où les premières et deuxièmes lignes conductrices sont disposées dans la région de COG,

caractérisé en ce que

la couche d'isolation de grille comprend un premier prolongement, et

dans lequel les premières lignes conductrices sont interposées entre le premier prolongement de la couche d'isolation de grille et la couche d'isolation intermédiaire, où la couche d'isolation intermédiaire comprend un deuxième prolongement, et où les deuxièmes lignes conductrices sont interposées entre le deuxième prolongement de la couche d'isolation intermédiaire et le réseau de pixels électroluminescents organiques et les premières et deuxièmes lignes conductrices sont essentiellement parallèles entre elles et ne se chevauchent pas lorsqu'elles sont vues dans une direction essentiellement perpendiculaire à la surface supérieure.

2. Dispositif selon la revendication 1, dans lequel les premières lignes conductrices (32) sont réalisées en un même matériau que l'électrode de grille.

3. Dispositif selon l'une quelconque des revendications précédentes, dans lequel les deuxièmes lignes conductrices (34) sont réalisées en un même matériau que les électrodes de source et de drain (14e et 14f).

4. Dispositif selon l'une des revendications précédentes, dans lequel les premières lignes conductrices (32) et les deuxièmes lignes conductrices (34) sont disposées dans un ordre alternatif le long d'une direction essentiellement parallèle à la surface supérieure.

5. Dispositif selon l'une des revendications précédentes, dans lequel les signaux transmis à travers les premières lignes conductrices (32) sont différents des signaux transmis à travers les deuxièmes lignes conductrices (34).

6. Dispositif selon l'une des revendications précédentes, dans lequel le réseau de pixels électroluminescents organiques définit une région d'affichage confinée par les premier et deuxième substrats (10 et 20) le long d'une première direction essentiellement perpendiculaire à la surface supérieure et par une surface périmétrique le long d'une deuxième direction essentiellement parallèle à la surface supérieure, dans lequel la surface périmétrique s'étend entre les premier et deuxième substrats et est perpendiculaire à la surface supérieure.

7. Dispositif selon la revendication 6, dans lequel le réseau de pixels électroluminescents organiques est prévu dans la région d'affichage, et dans lequel le transistor à couche mince (14) est prévu dans la région d'affichage. 5
8. Dispositif selon la revendication 6 ou 7, dans lequel la pluralité de lignes conductrices sont prévues dans une région de non-affichage, dans lequel la région de non-affichage comprend une région entre les premier et deuxième substrats (10 et 20), et dans lequel la région de non-affichage renferme la surface périmétrique de la région d'affichage. 10
9. Dispositif de la revendication 8, dans lequel la région de non-affichage comprend en outre une région de puce sur verre (COG), où la pluralité de lignes conductrices est formée dans la région de COG. 15
10. Dispositif selon l'une des revendications précédentes, dans lequel les premières et deuxième lignes conductrices (32 et 34) sont destinées à transmettre des signaux au transistor à couche mince (14). 20
11. Procédé de fabrication d'un dispositif d'affichage électroluminescent organique, le procédé comprenant le fait : 25
- de former une couche semi-conductrice (14a) sur un premier substrat (10) ; 30
- de former une couche d'isolation de grille (14b) qui comprend un premier prolongement sur la couche semi-conductrice ;
- de former une électrode de grille (14c) et des premières lignes conductrices (32) directement sur la couche d'isolation de grille ; 35
- de former une couche d'isolation intermédiaire (14d) qui comprend un deuxième prolongement sur l'électrode de grille et les premières lignes conductrices, où les premières lignes conductrices sont interposées entre le premier prolongement de la couche d'isolation de grille et la couche d'isolation intermédiaire ; 40
- de former des deuxième lignes conductrices (34) sur la couche d'isolation intermédiaire, où les premières et deuxième lignes conductrices sont essentiellement parallèles entre elles et ne se chevauchent pas lorsqu'elles sont vues dans une direction essentiellement perpendiculaire à la surface supérieure ; 50
- de former des électrodes de source et de drain (14e et 14f) sur la couche d'isolation intermédiaire ;
- de former une couche d'aplatissement (16) sur les électrodes de source et de drain ; 55
- de former un réseau de pixels électroluminescents organiques sur la couche d'aplatissement, où les deuxième lignes conductrices sont interposées entre le deuxième prolongement de la couche d'isolation intermédiaire et le réseau de pixels électroluminescents organiques ; et de former une région de puce sur verre (COG) qui ne se chevauche pas avec le réseau de pixels électroluminescents organiques, où les premières et deuxième lignes conductrices sont disposées dans la région de COG.
12. Procédé selon la revendication 11, comprenant en outre le fait de former la couche d'aplatissement (16) sur les deuxième lignes conductrices (34).

FIG.1

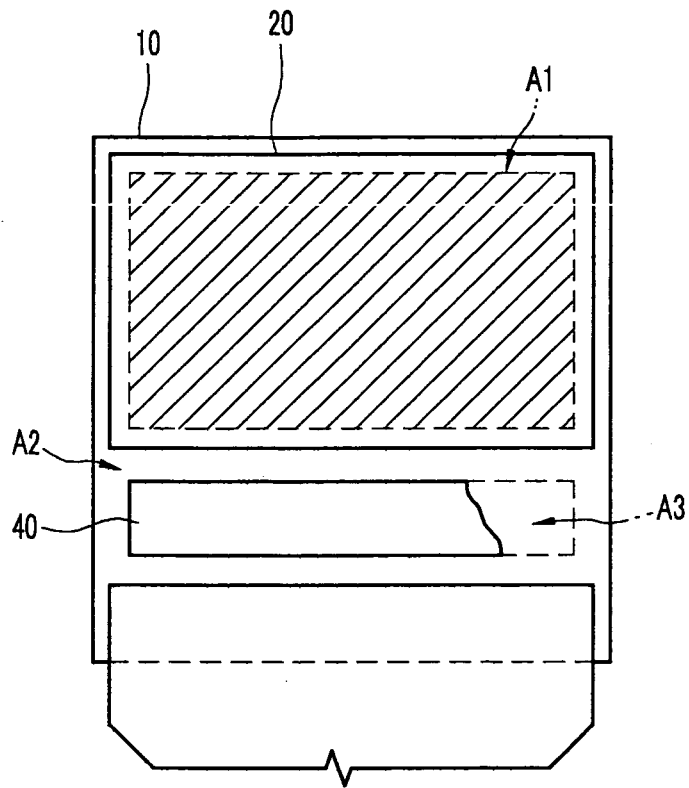


FIG.2

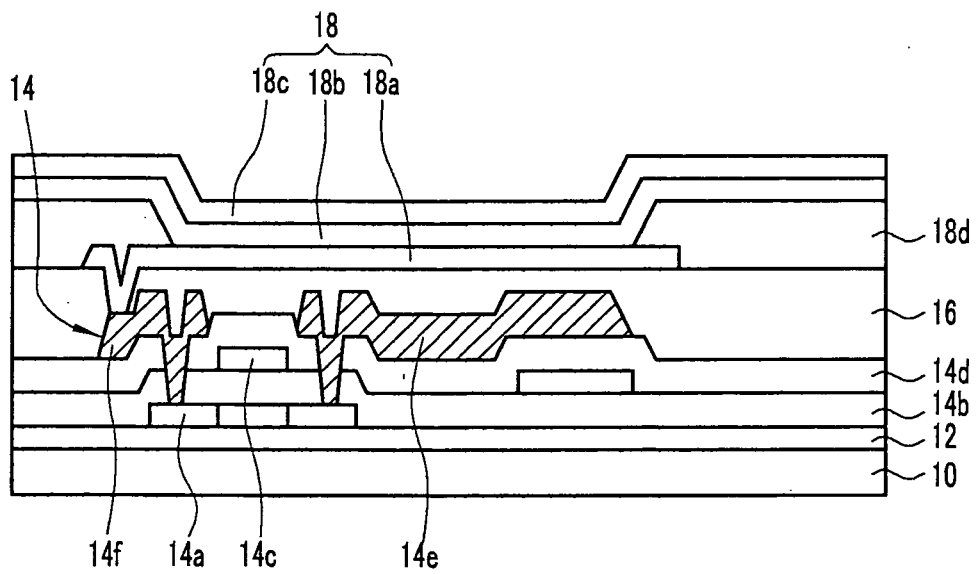


FIG.3

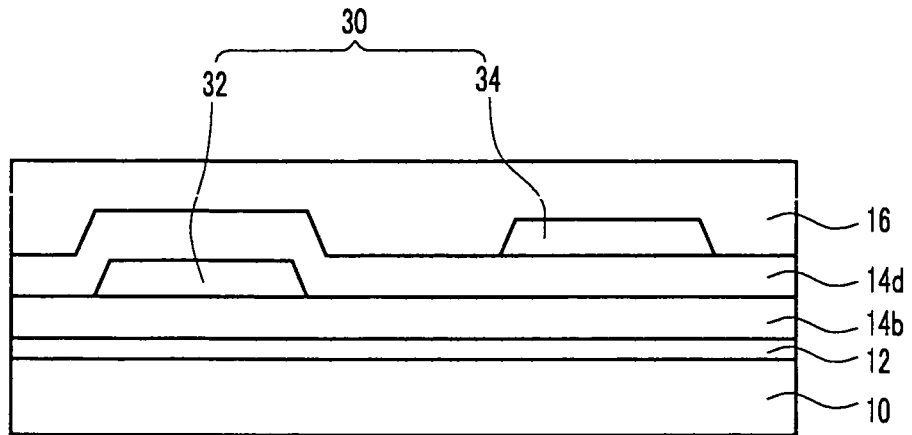
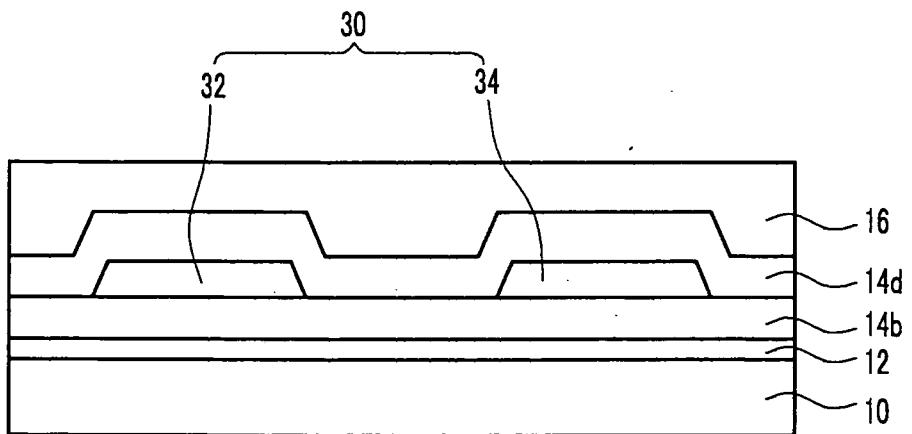


FIG.4



REFERENCES CITED IN THE DESCRIPTION

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Patent documents cited in the description

- US 20060044504 A [0028]
- JP 2005011571 A [0028]

专利名称(译)	有机发光显示器		
公开(公告)号	EP1895593B1	公开(公告)日	2017-05-10
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[标]申请(专利权)人(译)	三星斯笛爱股份有限公司		
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当前申请(专利权)人(译)	三星DISPLAY CO. , LTD.		
发明人	KIM, EUN-AH, SAMSUNG SDI CO., LTD.		
IPC分类号	H01L27/32		
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优先权	1020060083527 2006-08-31 KR		
其他公开文献	EP1895593A2 EP1895593A3		
外部链接	Espacenet		

摘要(译)

提供一种有机发光显示器。在有机发光显示器中，当包括用于将信号传输到驱动电路单元或有机发光器件的多条信号线（32,34）的布线部分（30）形成在非显示区域下时，更具体地，安装驱动IC的COG区域，布线部分（30）的信号线（32,34）设置在两个或更多个不同的层（14b，14d）上，以保持相邻信号线（32）之间的高度差，34）用于彼此传输不同的信号。

